### 10705410 CLS

Most Frequently Occurring Classifications of Patents Returned From A Search of 10705410 on June 16, 2004

## Original Classifications 6 378/34 5 250/504R 5 355/53 2 250/492.1 2 250/492.2 2 355/30 2 355/67 2 378/119 2 430/270.1 Cross-Reference Classifications 6 355/67 6 378/119 5 355/72 4 250/493.1 3 250/492.2 3 355/53 3 378/35 2 250/492.3 2 355/30 2 355/76 2 359/853 2 359/859 2 378/143 Combined Classifications 8 355/53 8 355/67 8 378/119 7 378/34 6 250/504R 5 250/492.2 5 250/493.1 5 355/72 4 355/30 3 250/492.1 3 359/859 3 378/35 2 250/492.3 2 355/68

2 355/752 355/762 356/499

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- 356/515
- 356/520
- 356/521 359/361
- 2 2 2 2 2 2 2 2 359/366
- 359/853 378/143
- 378/85
- 430/270.1

10705410\_CLSTITLES
Titles of Most Frequently Occurring Classifications of Patents Returne

From A Search of 10705410 on June 16, 2004

		•	
8		OR, 3 XR) : PHOTOCOPYING PROJECTION PRINTING AND COPYING CAMERAS .Step and repeat	
8	355/67 (2 Class 355 355/18 355/67	: PHOTOCOPYING	
8	378/119 (2 Class 378 378/119	: X-RAY OR GAMMA RAY SYSTEMS OR DEVICES	
7	378/34 (6 Class 378/ 378/1 378/34	OR, 1 XR) : X-RAY OR GAMMA RAY SYSTEMS OR DEVICES SPECIFIC APPLICATION .Lithography	
6	250/493.1 250/503.1	OR, 1 XR) : RADIANT ENERGY RADIANT ENERGY GENERATION AND SOURCES .With radiation modifying memberUltraviolet or infrared source	
5	250/492.1	OR, 3 XR) : RADIANT ENERGY IRRADIATION OF OBJECTS OR MATERIAL .Irradiation of semiconductor devices	
5	·	OR, 4 XR) : RADIANT ENERGY RADIANT ENERGY GENERATION AND SOURCES	
5		OR, 5 XR) : PHOTOCOPYING PROJECTION PRINTING AND COPYING CAMERAS .Detailed holder for photosensitive paper	
4		OR, 2 XR) : PHOTOCOPYING PROJECTION PRINTING AND COPYING CAMERAS .With temperature or foreign particle cont	crol

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3 250/492.1
              (2 OR, 1 XR)
       Class 250: RADIANT ENERGY
       250/492.1
                    IRRADIATION OF OBJECTS OR MATERIAL
3 359/859
               (1 OR, 2 XR)
       Class 359: OPTICS: SYSTEMS
       359/838
                    MIRROR
                   .Plural mirrors or reflecting surfaces
       359/850
       359/857
359/858
                    ..With successive reflections
                    ... Including curved mirror surfaces in series
       359/859 ....With concave and convex mirrors in series
3 378/35
              (0 OR, 3 XR)
       Class 378 : X-RAY OR GAMMA RAY SYSTEMS OR DEVICES
       378/1
                    SPECIFIC APPLICATION
       378/34
                   .Lithography
       378/35
                    ..Pattern mask
2 250/492.3
              (0 OR, 2 XR)
       Class 250: RADIANT ENERGY
       250/492.1 IRRADIATION OF OBJECTS OR MATERIAL
                  .Ion or electron beam irradiation
       250/492.3
               (1 OR, 1 XR)
2 355/68
       Class 355: PHOTOCOPYING
       355/18
                    PROJECTION PRINTING AND COPYING CAMERAS
       355/67
                   .Illumination systems or details
                    .. Including photocell or phototube
       355/68
               (1 OR, 1 XR)
2 355/75
       Class 355: PHOTOCOPYING
       355/18
                   PROJECTION PRINTING AND COPYING CAMERAS
       355/75
                    .Detailed holder for original
2 355/76
               (0 OR, 2 XR)
       Class 355: PHOTOCOPYING
       355/18
                   PROJECTION PRINTING AND COPYING CAMERAS
       355/75
                    .Detailed holder for original
       355/76
                    .. Including vacuum, fluid or spring pressure
2 356/499
               (1 OR, 1 XR)
       Class 356: OPTICS: MEASURING AND TESTING
                   BY LIGHT INTERFERENCE (E.G., INTERFEROMETER)
       356/450
       356/496 .For dimensional measurement
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        356/498
                      ..Displacement or distance
        356/499
                      ... Having wavefront division (e.g., by
                        diffraction)
                (1 OR, 1 XR)
2 356/515
        Class
               356: OPTICS: MEASURING AND TESTING
        356/450
                     BY LIGHT INTERFERENCE (E.G., INTERFEROMETER)
                     .For dimensional measurement
        356/496
        356/511
                     .. Contour or profile
        356/512
                     ... By wavefront detection
        356/515
                     ....Of transmission (e.g., lens)
  356/520
                (1 OR, 1 XR)
                356 : OPTICS: MEASURING AND TESTING
       Class
        356/450
                     BY LIGHT INTERFERENCE (E.G., INTERFEROMETER)
        356/520
                     .Having shearing
  356/521
                (1 OR, 1 XR)
        Class
               356 : OPTICS: MEASURING AND TESTING
                     BY LIGHT INTERFERENCE (E.G., INTERFEROMETER)
        356/450
        356/521
                     .Having wavefront division (by diffraction)
                 (1 OR, 1 XR)
  359/361
               359 : OPTICS: SYSTEMS
       Class
        359/350
                     HAVING SIGNIFICANT INFRARED OR ULTRAVIOLET
                         PROPERTY
                      .Having ultraviolet absorbing or shielding
        359/361
                        property
2 359/366
                (1 OR, 1 XR)
               359 : OPTICS:
                               SYSTEMS
        Class
        359/362
                     COMPOUND LENS SYSTEM
        359/364
                     .With curved reflective imaging element
                     .. Two or more in a series
        359/365
        359/366
                     ... Concave, convex combination
                (0 OR, 2 XR)
2 359/853
               359 : OPTICS: SYSTEMS
       Class
        359/838
                     MIRROR
                     .Plural mirrors or reflecting surfaces
        359/850
        359/851
                     .. Composite or echelon mirrors or light
                         concentrating array
                      ...Light concentrating (e.g., heliostat, etc.)
        359/853
                        concave, or paraboloidal structure
2 378/143
               (0 OR, 2 XR)
       Class 378: X-RAY OR GAMMA RAY SYSTEMS OR DEVICES
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	378/119 378/143		SOURCE .Target
2	378/85	(1	OR, 1 XR)
	Class 378/1	378	: X-RAY OR GAMMA RAY SYSTEMS OR DEVICES SPECIFIC APPLICATION
	378/70	•	.Diffraction, reflection, or scattering analysis
	378/82		Spatial energy dispersion
	378/84		Monochromator or focusing device
	378/85		With plural dispersing elements
2	430/270.1	(2	OR, 0 XR)
	Class	430	: RADIATION IMAGERY CHEMISTRY: PROCESS, COMPOSITION, OR PRODUCT THEREOF
	430/269		IMAGING AFFECTING PHYSICAL PROPERTY OF RADIATION SENSITIVE MATERIAL, OR PRODUCING
NONE	PLANAR OR		· · · · · · · · · · · · · · · · · · ·
			PRINTING SURFACE - PROCESS, COMPOSITION, O
R PRO	DUCT		
	430/270.	1	.Radiation sensitive composition or product or process of making